	Application No.	Applicant(s)
Notice of Allowahility	10/624,583	DOMSCHKE ET AL.
Notice of Allowability	Examiner	Art Unit
	Tatyana Zalukaeva	1713
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGORY OF THE OFFICE OF UPON PETITION BY THE OFFICE OF UPON PETITION BY THE OFFICE OF THE OFFICE OFFICE OF THE OFFICE OF THE OFFICE	or other appropriate communication  GHTS This application is subject to	olication. If not included
1. This communication is responsive to <u>09/28/2004</u> .		
2.  The allowed claim(s) is/are 12-18.		
3. The drawings filed on are accepted by the Examiner.		
4. ☐ Acknowledgment is made of a claim for foreign priority und a) ☐ All b) ☐ Some* c) ☐ None of the:  1. ☐ Certified copies of the priority documents have I 2. ☐ Certified copies of the priority documents have I 3. ☐ Copies of the certified copies of the priority documents have I	been received. been received in Application No	 ational stage application from the
International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONME THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	f this communication to file a reply c NT of this application.	omplying with the requirements
5. A SUBSTITUTE OATH OR DECLARATION must be submitted INFORMAL PATENT APPLICATION (PTO-152) which gives	ed. Note the attached EXAMINER'S reason(s) why the oath or declarati	S AMENDMENT or NOTICE OF on is deficient,
6. CORRECTED DRAWINGS (as "replacement sheets") must be	be submitted	•
<ul><li>(a) ☐ including changes required by the Notice of Draftspersor</li></ul>	n's Patent Drawing Review ( PTO-94	48) attached
r) ☐ nereto or 2) ☐ to Paper No./Mail Date	<b>'</b> ·	
(b) including changes required by the attached Examiner's A Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84 each sheet. Replacement sheet(s) should be labeled as such in the	l(c)) should be written on the drawing header according to 37 CFR 1 121(d)	s in the front (not the back) of
<ol> <li>DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT FO</li> </ol>	of BIOLOCICAL MATERIAL	
•		*
Attachment(s)  1. ☑ Notice of References Cited (PTO-892)		
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	5. Notice of Informal Pate	ent Application (PTO-152)
3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SR/08)	6. ☐ Interview Summary (P Paper No./Mail Date	
Paper No./Mail Date  1. Examiner's Comment Regarding Requirement for Deposit		
of Biological Material	8. ⊠ Examiner's Statement 9. ☐ Other	of Reasons for Allowance

## REASONS FOR ALLOWANCE

## Allowable Claims

- 1. Claims 12-18 are allowed over the prior art of record.
- 2. The following is an examiner's statement of reasons for allowance: It is noted here that Examiner has different reasons for allowance than those advanced by Applicants in their remarks. Claims 12-18 are product-by-process claims, wherein the patentability of the product, although can depend on the process of its making, is, however, defined by the product per se. From the teaching of the instant Specification Examiner concluded that the properties of the product, such as cell growth and water retention are superior in the product due to the process of making it wherein the polymerization is performed at a temperature around the cloud point, and the porogen is removed at a temperature below the cloud point of the composition. This is not taught or suggested by Hennik, wherein the porogen is retained in the polymer network.

Several other references have been discovered as of the day of this communication that teach the removal of porogen from a polymer network after polymerization;

Roberts 2002/0077036 discloses porous polishing layer made of polymer by 1) creating a polymeric layer with one or more polymers and incorporating porogens into the polymeric layer wherein the polymers are more resistant to degradation relative to the porogens and ensuring that the porogens are substantially uniformly dispersed in the polymeric layer; 2) curing the polymeric layer without substantially removing the

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porogens; and 3) curing the polymeric layer to remove the porogens without adversely affecting the surrounding polymeric matrix to form a porous polishing layer. However, the porogen is incorporated after polymerization, and there is no teaching or suggestion for removing the porogen at below cloud point temperature, wherein the polymerization is performed at around cloud point temperature.

Embil et al (U.S. 5,985,319) discloses porous materials wherein one or more suitable monomers are polymerized in the presence of a dispersed porogen, after polymerization the porogen can be removed by evaporation or solvent extraction.

However, there is no suggestion or teaching that a product is obtained under conditions of the instant invention, and therefore has the properties of the instantly claimed product.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tatyana Zalukaeva whose telephone number is (571) 272-1115. The examiner can normally be reached on 9:00 - 5:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Wu can be reached on (571) 272-1114. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Tatyana Zalukaeva Primary Examiner Art Unit 1713

December 3, 2004

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